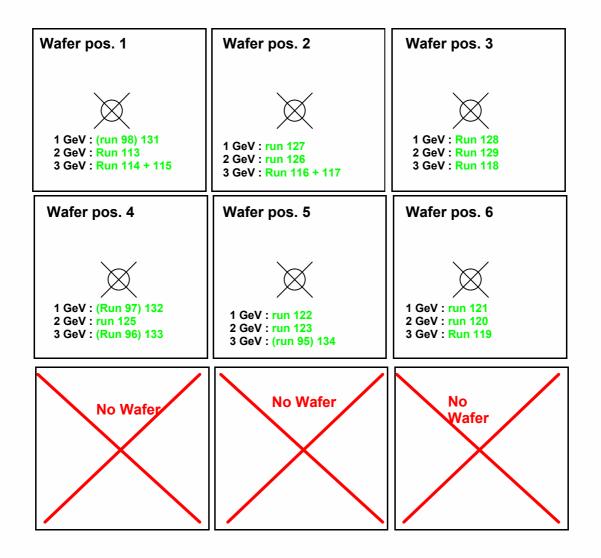
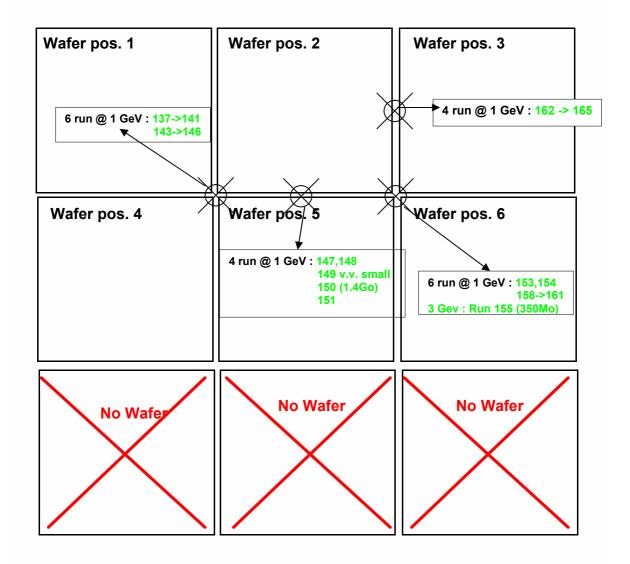
Shift planning

1 – Shot at the middle of each wafer with 1, 2 and 3 GeV (One Run of 190000 events seems to be enough at each value of energy)



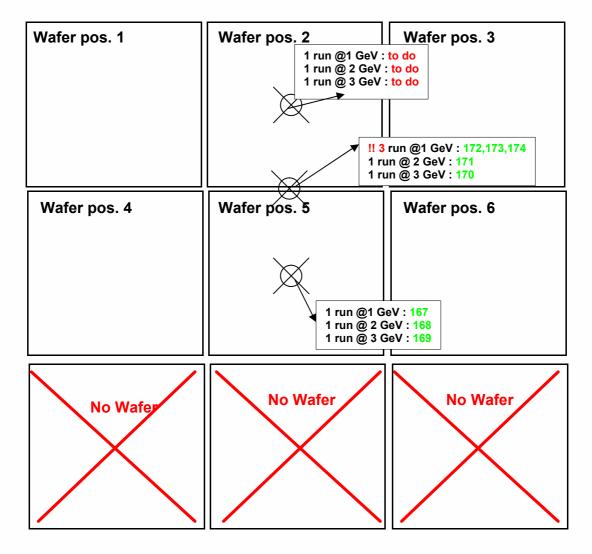
2 – Shot between wafer with 1 GeV

(4 or 6 Run of 190000 events at each position) BECAREFULL some MODIFICATION IN NUMBER OF RUN



3 – ECLA at 30° Shot at the middle of each wafer with 1, 2 and 3 GeV

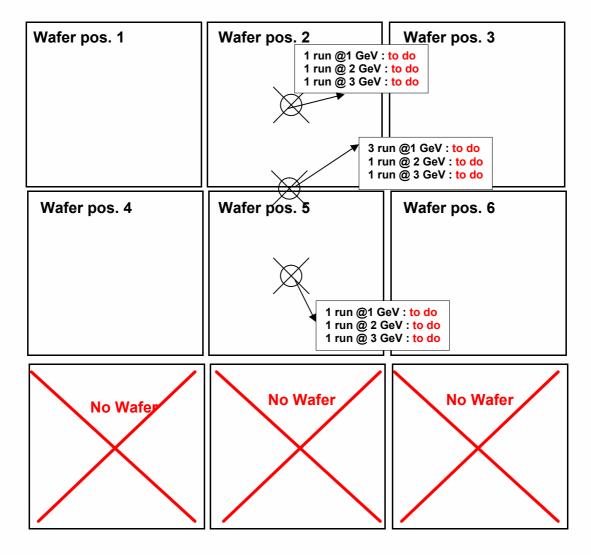
(One Run of 190000 events seems to be enough at each value of energy)



Attention: The changing from one angular position to another is not trivial, so we foresee to have both Marc Anduze and Jean Charles Vanel on site at least for the first change.

4 – ECLA at 20° Shot at the middle of each wafer with 1, 2 and 3 GeV

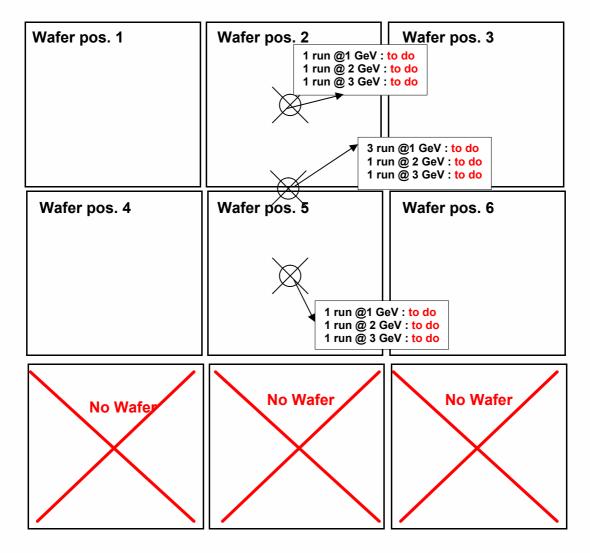
(One Run of 190000 events seems to be enough at each value of energy)



Attention: The changing from one angular position to another is not trivial, so we foresee to have both Marc Anduze and Jean Charles Vanel on site at least for the first change.

5 – ECLA at 10° Shot at the middle of each wafer with 1, 2 and 3 GeV

(One Run of 190000 events seems to be enough at each value of energy)



Attention: The changing from one angular position to another is not trivial, so we foresee to have both Marc Anduze and Jean Charles Vanel on site at least for the first change.